**Tuning of the Copper-Zirconia Phase Boundary for
Selectivity Control of Methanol Conversion**

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Abstract

Chemical-vapor deposition (CVD) of a $\text{Zr}(\text{O-tBu})_4$ precursor on different Cu substrates was used to prepare model systems for ZrO_xH_y -Cu catalysts and to test their reactivity and selectivity in methanol steam reforming (MSR). A partially hydroxylated and initially fully oxidized submonolayer ZrO_xH_y surface species results, exhibiting a pronounced catalytic synergism between the ZrO_xH_y overlayer and Cu only with respect to partial methanol dehydrogenation to formaldehyde. Thus, it differs strongly from *in situ* grown ZrO_xH_y layers on Cu formed from an initially bimetallic mixed Zr/ZrO_x state under MSR conditions. CVD-grown Zr-OH groups are not stable under MSR conditions, thus reversible *in situ* hydroxylation and water-activating reaction channels are suppressed. Comparison of both model systems indicates that only a dedicated Cu- ZrO_xH_y interface with *in situ* formed and reversibly hydroxylated sites, accessible only from initially (inter)metallic Cu/Zr species at the surface, leads to water activation, total oxidation of intermediate formaldehyde and enhanced CO₂ selectivity.

1. Introduction

Copper-based catalysts are widely used for applications in methanol chemistry, whereby controllable steering of product selectivity is a key criterion for technical usage. This particularly applies to the technical formaldehyde production from methanol. The other examples are methanol synthesis from syngas with optimized CO/CO₂ ratio, hydrogenation/photo-reduction of CO₂ [1] to produce “renewable” methanol, and methanol steam reforming (MSR) as the reversal of the synthesis reaction from CO₂. MSR is an important route for H₂ synthesis. In order to realize the efficient on-board production of clean hydrogen in automotive applications, the key targets of MSR are high CO₂ selectivity, low CO content and maximum H₂ yield [2]. Methanol partial oxidation is performed on Cu-based catalysts trimmed towards maximum formaldehyde selectivity [3], where *in situ* observed subsurface oxygen is likely highly relevant and plays a key role [4, 5]. All these systems trigger different reaction channels on Cu via various dopants. Three kinds of catalytic relevant Cu surfaces can be defined: very clean Cu that provides no sites for methanol (and water) activation, subsurface activated Cu that opens partial oxidation reaction routes by enabling MeOH activation and H₂ desorption but at the same time stabilizing formaldehyde, and bi-functional Cu surfaces/interfaces that, via Cu interaction with dopant atoms/ species, provide sites for H₂O activation and methanol activation at the same time [6]. Therefore, clear understanding of Cu-dopant interactions is inevitable for the further development and improvement of industrially applied catalysts, especially upon consideration that enormous differences in product-selectivity can be obtained by small, but directed changes in the catalyst preparation procedure. Selectivity control is thereby realized by suppression of full dehydrogenation of methanol to CO and subsequent promotion of desired partial or total reaction channels, that is, either formaldehyde formation via partial dehydrogenation and fast desorption or, for MSR, total oxidation of intermediate oxygenates, such as HCHO, to CO₂ by co-adsorbed water.

With respect to the catalytic function of zirconia, already the simple addition of ZrO_2 to the conventionally used Cu/ZnO catalysts allows not only for reducing the inherent drawback of purely ZnO -based catalysts, that is, the poor sintering stability of the Cu particles, but also to enhance MSR selectivity [2]. Synergistic Cu-ZrO_2 interactions have also been reported for Cu/ZrO_2 catalysts without ZnO , involving Cu-O-Zr bonds at the phase boundary, which are believed to play a crucial role in steering the methanol reforming reaction to maximize CO_2 selectivity [7-10]. Specifically, a nanocrystalline copper/tetragonal ZrO_2 catalyst synthesized by a polymer templating technique [6] was reported to be more active, more CO_2 -selective and more stable in MSR than the technical $\text{Cu/ZnO/Al}_2\text{O}_3$ methanol synthesis catalyst [11]. Although a beneficial effect of the redox chemistry of Cu and the $\text{Cu}^0/\text{Cu}^{\text{oxidized}}$ ratio at the interface is put forward as an important selectivity descriptor, alongside disorder and strain phenomena within the metallic Cu phase [2], contradicting influence has also been reported. Both beneficial [7, 8] and adverse [10] effects of the reducibility of Cu are found in literature. Nevertheless, any influence appears strongly connected to the quantity and quality of the, especially *in situ* formed, Cu-ZrO_2 interface. This is important insofar as also the oxide part of the catalyst may synergistically participate in the reaction, either by stabilizing oxygenate intermediates or by activating water [2]. The latter has already been identified on the corresponding Pd-ZnO [12] and Cu-ZnO [13] systems as the most important step in CO_2 -selective steam reforming.

As it is known from previous studies on an intermetallic Cu-Zr pre-catalyst state [14] and the works of other groups [6], a Cu/ZrO_2 or $\text{Cu/ZrO}_x\text{H}_y$ interface, providing active and selective sites for the methanol steam reforming (MSR) reaction, is a structural pre-requisite. Furthermore, it is crucial to obtain a bi-functional surface that can activate methanol and water at the same time for high CO_2 selectivity and consequently, a high H_2 yield with minimized CO contamination.

The partial oxidation of methanol to formaldehyde, a process of high industrial relevance, applies the different requirements for a catalytic surface. No water activation is required. However, efficient methanol activation along with stabilization of formaldehyde against full dehydrogenation and selective oxidative removal of H_2 is still required. For the latter, O_2 -activation toward a suitable oxygen surface/subsurface species, which should mainly react with H_2 toward water and not with formaldehyde toward formates/ CO_2 , is mandatory. Although specifically activated O_{sub}/Cu itself can provide the selective dehydrogenation/ H_2 -oxidation functionality [15], i.e. providing active sites both for methanol activation and for formaldehyde stabilization, this otherwise dopant-free form of Cu at the same time only poorly activates water. Moreover, as shown in this work, ultra-clean and oxygen-free copper is hardly active for both processes. The activation for formaldehyde formation is shown and discussed in detail in the first part of the catalytic section of this work (3.B.). Water activation and H_2 desorption are obviously provided by the ZrO_xH_y species originating from Zr^0 oxidation/hydroxylation, and their chemical state is as important as their surface structure (essentially differing from bulk ZrO_2 structures, since the overlayer thickness is <1 ML). As for specific Cu- ZrO_2 systems, the interface of CuO with tetragonal ZrO_2 , prepared via a sol-gel technique, showed high CO_2 -selectivity and acceptable activity [6]. O_2 /air oxidation of a Cu-Zr glassy alloy was investigated, however the activity and selectivity was found to be not satisfying [16, 17] and, therefore, an additional additive of novel metals is required for these systems. This indicates the absence of active Cu/ ZrO_xH_y sites, most likely due to high temperature oxidative treatments and also brings along new CO_2 -selectivity issues by i.e. the opening of a full dehydrogenation pathway on Pd.

On the other hand, our own dedicated model catalyst studies showed enhanced CO_2 selectivity for an *in situ* oxidized, initially Cu/ Zr^0 bimetallic state, intimately linked to reversible surface hydroxylation and associated formation of ZrO_xH_y layers [14]. Whether initially hydroxylated ZrO_xH_y species formed via CVD of Zr (O-tBu) $_4$ (ZTB) could feature

the same positive effects on the CO₂-selectivity (providing comparably active and selective sites in terms of formaldehyde stabilization and H₂O activation) represented the original focus of this study.

In the present study we exemplify the surprising and unexpected versatility of differently prepared inverse Cu-ZrO_xH_y phase boundary model systems for selective control of these reaction channels. Specifically, focus was put on the growth of ZrO_xH_y submonolayers on Cu by chemical vapor deposition (CVD) with the prime intention to prepare a catalytically active, bi-functional Cu-ZrO_xH_y interface. The CVD-prepared layer therefore was not supposed to act as a fully surface-covering protection layer like in many other ALD/CVD applications [15], but to be a co-functional part of the catalytically active interfacial species itself.

In due course, the growth, annealing behavior and associated catalytic performance of these CVD-prepared model catalysts has been thoroughly tested. Both a Cu(111) single crystal and a polycrystalline Cu foil were chosen as substrates and (sub)monolayers of ZrO_xH_y were accordingly prepared by exposure to gaseous ZTB in a UHV chamber with an attached high-pressure reaction cell. State-of-the art surface science characterization of the pre- and post-catalysis states of the model surfaces was performed using X-ray Photoelectron Spectroscopy (XPS), Low-energy Ion Scattering Spectroscopy (LEIS), High-resolution Electron-Energy Loss Spectroscopy (HREELS) and Scanning Tunneling Microscopy (STM) and combined with dedicated reactivity studies in the UHV-compatible high-pressure catalytic reaction cell. Particular emphasis was given to a direct comparison of the model systems under otherwise identical experimental conditions in order to ensure quantitative comparability of rates and selectivities. Theoretical calculations (DFT) have been performed to substantiate the experimental results.

2. Experimental Setup

Two dedicated UHV chambers with complementary techniques were used for preparation and analysis and the corresponding results correlated via XP spectroscopy (i.e. spectra of equally prepared model surfaces were recorded in both chambers). The first setup, a dedicated Omicron surface science apparatus, equipped with HREELS, XPS and STM was used to investigate the CVD process and the prepared layers on Cu(111) under various reductive, oxidative and annealing conditions. In due course, XPS and catalytic performance were tested on polycrystalline Cu foils in a second UHV chamber, equipped with XP/Auger spectroscopy, low-energy ion scattering and an attached high-pressure batch-reactor. Additionally, *in situ* XPS measurements were performed at the ISS beamline of the BESSY II synchrotron in Berlin, Germany.

2.1. UHV-chamber with batch reactor

Cu foil sample preparation and characterization was performed in a combined preparation/analysis chamber with attached reaction cell, described in more detail elsewhere [19]. It exhibits a base pressure in the low 10^{-9} mbar range. The sample is heated via a home-built e-bombardment setup. Electrons are ejected from a triple-filament emitter (operated with 30 W heating power) set to -500 V, while the sample is set to +300. The electron impact heating power is then controlled via the filament emission current. For spectroscopic analysis, the chamber is equipped with a hemispherical electron and ion analyzer (Thermo Fisher Electron Alpha 110), a double anode X-ray gun (Mg/Al, XR 50, Specs) for XPS, an ion gun (Omicron 100) to produce 1 kV He^+ Ions for ISS (ion scattering spectroscopy) and an electron beam gun (KPI EGPS-2017B) for Auger electron spectroscopy. Additionally, a mass spectrometer (Balzers) for residual gas analysis and an Ar^+ ion sputter gun for sample cleaning are attached. A three-way gas inlet allows to dose O_2 (Messer, 5.0), H_2 (Messer 5.0) or O_2 depleted Ar (Messer Ar 5.0, via Supelpure®-O Oxygen/Moisture trap) via leak valves into the chamber.

All XPS spectra collected in this chamber were recorded using a non-monochromatized Mg K_{α} X-ray radiation ($h\nu = 1253.6$ eV) at 250 W and at the “magic angle” of $\alpha=54.74^{\circ}$ between radiation and the energy analyzer. The analyzer was operated using a constant pass energy of 20 eV.

For catalytic testing in the high-pressure cell, a long z-transfer rod allows fast and reliable transfer without exposure to air. The all-quartz-glass high-pressure (up to 1 bar) batch reactor is equipped with a gas chromatograph with either intermediate or continuous EID-MS detection to determine the exact gas composition at any point of reaction. Continuous partial pressure detection is performed via a capillary leak to the EID detector. The quartz-glass reactor with a total circulation volume of 296 ml was designed to measure small reaction rates and selectivity patterns within a temperature range of room temperature up to 1300 K. A circulation pump ensures a constant flow and gas intermixing and an attached gas-premixing unit allows to set arbitrary compositions of the attached gases (methanol, methane, deionized and degassed water, O_2 , H_2 , CO, CO_2 , Ar and He). The sample holder itself is entirely made of quartz glass to avoid background reactivity from hot metal parts and is designed for 20 mm x 18 mm metal foils.

A partial pressure of 8 mbar Argon added to all gas mixtures allows to correct for the thermal expansion due to the temperature increase and the simultaneous gas loss through the capillary leak for continuous MS detection. For partial pressure calculations, all base-line-corrected-MS signals were calibrated using pure substances with quantitative consideration of fragmentation. For all catalytic experiments shown in this work, the following initial conditions for MSR were applied: 12 mbar Methanol, 24 mbar water, 8 mbar Argon and He added to 1 bar total pressure. After an equilibration time of 10 min, a temperature ramp of 10 K min^{-1} up to 623 K was performed, followed by an isothermal period at 623 K. As for mass and heat transport limitations, we refer to a thorough discussion of the catalytic setup in ref. [19].

All catalytic experiments were performed using a 20 mm x 18 mm ultra-clean Cu foil (99.9999%, Alfa Aesar) with a thickness of 0.125 mm. For reference experiments a 0.127 mm Zr foil (99.95%, Alfa Aesar) was used. The foils were cleaned before loading to the UHV chamber in a water and an ethanol ultrasonic bath for 20 min, respectively.

2.2. Omicron UHV set-up

The HREEL spectra (LK HREELS 5000), the STM images as well as the corresponding XP spectra were recorded in an Omicron analysis chamber with a base pressure of 5×10^{-11} mbar. The experimental set-up was described in detail elsewhere [20, 21]. An attached preparation chamber was used for sample cleaning and sample preparation. It is equipped with an Ar^+ sputtering gun and a gas manifold system. Sample heating for the CVD process was done resistively and the temperature controlled with a K-type (chromel–alumel) thermocouple. For HREELS and STM, a Cu(111) single crystal was used because of suitable mounting on the sample holder in the Omicron setup and the better defined surface, resulting in higher intensity and better resolution in the HREEL spectra and STM images. XPS data were acquired using a non-monochromatized $\text{MgK}\alpha$ X-ray source ($h\nu = 1253.6$ eV) at 150 W. High resolution spectra were recorded at the constant pass energy of 20 eV and a photoelectron ejection angle of 45° (with respect to the surface normal).

2.3. *In situ* Instrument

Synchrotron-based *in situ* XPS experiments were performed at the ISIS (Innovative Station for *In Situ* Spectroscopy) beamline at the BESSY II synchrotron in Berlin, Germany. The experimental apparatus consists of a load lock and *in situ* cell connected to the photoemission spectrometer via differential pumping stages. It has been described in the literature

extensively [22]. Samples were heated in the *in situ* cell via a near-infrared semiconductor laser ($\lambda = 808$ nm) from the rear. Temperature was measured by a K-type (chromel–alumel) thermocouple positioned between sample holder back plate and Cu foil. All *in situ* experiments were performed on the same ultra-pure Cu foil that was used for the model catalyst preparations in the UHV instrument with attached batch reactor (see section 2.1). Also, the same ZTB cylinder/ leak valve setup was transferred to ISIS beamline. Due to the fact that ZTB only interacts with surfaces hotter than 500 K, it was safe to dose the organometallic precursor into the analysis chamber without any Zr deposition on the components of the vacuum system or on the x-ray window. The growth of ZTB could then be followed *in situ* via XPS.

In order to extract information from a constant depth, photon energies were chosen (via the monochromator control) to have a kinetic energy of the emitted photoelectrons of ~ 120 eV for all monitored core-level photoemission peaks. Due to the fact that $\sim 95\%$ of the signal arises from a sample depth up to ~ 1 nm (electron attenuation length is ~ 0.37 nm at 120 eV for Cu $2p_{3/2}$ in copper [23]), this operation mode is called “surface sensitive”.

Photoelectrons were collected in the normal direction to the surface at constant pass energy of 10 eV. Binding energies were referenced to the Fermi edge, which was measured each time the monochromator settings changed (i.e. whenever the incident photon energy was changed). Photoemission peak intensities were corrected for the photon flux at a given photon energy. Since the BESSY II synchrotron operates in top-off mode (constant ring current), no correction for the ring current was required. Since all photoemission peaks were collected at the same kinetic energy of photoelectrons (120 eV), the attenuation through the gas phase was the same for all core-levels and thus cancels out in coverage calculations.

2.3. Sample Preparation

Before Zr deposition, the samples were cleaned carefully via several cycles of Ar⁺ sputtering/annealing and the purity checked by XPS, in case of the Omicron setup by STM as well. All possible impurities were below the XPS detection limit for all prepared model catalysts.

Exposure to the CVD precursor (ZTB) was performed in the preparation chamber for the Omicron set-up and in the combined preparation/analysis chamber for the UHV-chamber with attached batch reactor. In the *in situ* measurements, the ZTB was dosed during XPS measurements.

For the CVD process, the sample was heated up to 573-773 K (note the different sample heatings for the three systems). An ultra-clean Cu foil (99,999%) and accordingly, a Cu(111) single crystal (for the Omicron setup) were exposed to the volatile organometallic precursor at different template temperatures. Zirconium(IV)-tert-butoxide (Sigma Aldrich, purity: 99.999 %, for Omicron instrument: Strem, purity: 99%) was contained in a stainless steel cylinder and purified by several cycles of freeze-pump-thaw. It was then dosed under strict control of the sample temperature into the preparation chamber via a leak valve. The amount of dosing was varied between 100 L (3.3×10^{-7} mbar for 400 s) and 2000 L (6.6×10^{-6} mbar ZTB for 420 s). However, since the actual deposited film thickness highly depends on the sample temperature/pre-conditioning of the chamber walls, this value should be rather viewed as a rough estimate. For a much more accurate quantification of the deposited material, the film thickness and the surface coverage were calculated using Fadley's approach namely an attenuated overlayer model and a non-attenuated model, correspondently [24, 25]. The approach are described in the Supplementary Information. The Cu/ZrO_x surface ratio determined by LEIS allowed to subsequently establish a correlation between catalytic performance and the abundance of the ZrO_xH_y/Cu interface.

2.4. Analysis of the XPS Data

All spectra were analyzed using the CasaXPS software, version 2.3.16 Pre-rel 1.4 (Casa Software Ltd.) [26]. The area under a photoemission peak was measured after a Shirley background subtraction and was corrected for the associated Scofield relative sensitivity factors. For peak fitting of the Zr 3d peaks a weighted sum of Gaussian and Lorentzian peak shapes (CasaXPS line shape SGL(30)) was used. A fixed spin-orbital splitting doublet separation (Zr 3d_{5/2} vs. Zr 3d_{3/2}) of 2.4 eV for both metallic Zr [27] and zirconia [28] was used. The doublet area was constrained to be 3:2 as arising from spin-orbit splitting for d-electrons. Electron attenuation lengths were taken from the NIST database SR 82 [23] and the orbital asymmetric parameters from the ELETTRA online database of ref. [29] (cancelled out for the “magic” angle). The surface coverage was estimated by a non-attenuated overlayer model on a semi-infinite substrate for fractional coverages [25]. For thickness estimations, a model that considers photoelectron attenuation through the substrate and the overlayer was used. While the coverage estimation is more meaningful for sub-monolayer overlayer, a multi-monolayer film can be more accurately described by the attenuating overlayer model. For low thicknesses, the influence of the attenuation effect is low and therefore the results of both models (coverage in ML and thickness in Å) are convertible under consideration of the chemical composition of the overlayer. Details of these calculations are given in the Supplementary Information in Section A. For *in situ* XPS data, a photon flux was normalized for different photon energies.

3. Results and Discussion

3.A. ZrO_xH_y layer growth by CVD on Cu

3.A.1. Deposition of the layers

For deposition of ZrO_xH_y layers of ZTB on Cu, similar activation barriers appear as documented for e.g. ZTB on Si [30, 31]. A minimum temperature of around 573 K is required to observe any Zr on the surface. The Zr coverage increases with increasing sample temperature (and, at a given temperature, with the exposure in Langmuir). Finally reaches a maximum at around 693 K. At higher exposure temperatures, for a given exposure, the Zr coverage decreases and reaches zero above around 823 K. The ratio between C and Zr is highly influenced by the exposure temperature, but in all cases lower than 16 C atoms per Zr (referenced to the precursor). The carbon coverage is comparably low for the optimum temperature of 693 K. Therefore, this temperature was chosen for preparation of the Zr overlayers for catalytic experiments (for details see below). In contrast, at the minimum temperature of 573 K, a relatively high carbon coverage was found. Carbon coverages can be reduced by post-annealing treatments and approach zero at approximately 973 K. Despite the fact that the Zr/O ratio was hardly affected, annealing has a considerable effect on the prepared ZrO_xH_y layer (section 3.A.2 and 3.A.3).

Figure 1: Core-level Zr 3d spectra obtained (i) *in situ* during the growth of a ZrO_xH_y overlayer on a polycrystalline Cu foil at 693 K in 5×10^{-6} mbar ZTB (bottom set of the spectra), (ii) after ZTB pumping in vacuum at 693 K (middle spectrum) and (iii) at RT (top spectrum).

The prepared overlayer was further investigated by XPS and HREELS. To ensure direct comparison with the layer subsequently used for the catalytic experiments, the discussion of the spectra is restricted to the overlayer prepared at 693 K. This was also the temperature for the catalyst preparation due to the lowest C content and efficient Zr deposition. Figure 1 shows the *in situ* spectra during exposure of 5×10^{-6} mbar ZTB at 693 K (acquisition time for each spectrum 30 s). Note that a possible influence of the synchrotron X-ray on the

decomposition mechanism cannot be ruled out. During *in situ* ZTB exposure, the peak maxima of the Zr 3d_{5/2} state do not shift considerably. However, the Zr 3d_{3/2} peak shifts by ~0.9 eV (up to 183.3 eV) if ZTB was pumped off and the sample was cooled to RT. A detailed structural discussion, including the finding that the formed overlayer prefers a 2 ML thickness as distinguished from combined XPS and LEIS results and substantiated by DFT, can be found in section 3.C. and Figure S3.

As for the chemical state of the ZrO_xH_y overlayer, *ex situ* collected Zr 3d_{3/2} XPS peaks (Figure 2, “as grown”) show an up-shift from the Zr⁺⁴ (ZrO₂) state at 182.3 eV to 183.1 eV due to (partial) hydroxylation (Zr-(OH)₄ BE at 183.1 eV [32]). This shift correlates with the one observed for O 1s spectra: the O 1s peak is found at around 1 eV above the ZrO₂ position (~530.4 eV). Peak fitting in the O 1s region was not performed because of the fact that more compounds (i.e. carbon oxygenates) contributed to this region and an unambiguous peak fit can therefore not be performed. However, the trend in peak position is clear and is directly proven by additional HREEL spectra (cf. Figure 4, right panel c, “precursor state”; vibrational mode above 3650 cm⁻¹ indicating the presence of Zr-OH groups already in the as grown films). The position of the carbon peak in the C 1s spectra at 284.4-284.6 eV is characteristic for sp³-hybridized carbon in C-C and C-H entities.

Figure 2: XP spectra collected on a Cu(111) single crystal exposed at 693 K to obtain 0.1 ML ZTB. Starting from a freshly prepared sample, marked as “as grown”, vacuum annealing at 973 K was done first and then O₂ oxidation was performed. Cu 2p_{3/2}, C 1s, O 1s and Zr 3d peaks are shown in separate sub-panels.

3.A.2. High-temperature annealing

In vacuo and oxidative post-annealing of the as-prepared films in 5×10^{-7} mbar O₂ (by backfilling the UHV chamber) have been performed to better understand the transformation of the layers also during the catalytic reactions. These “reference” spectra were then used to assign the corresponding Zr chemical states. Moreover, post-treatment experiments on the Cu(111) single crystal performed by XPS, HREELS and STM were also used to correlate the observed Zr oxidation states after catalytic MSR treatments on Cu foils. Figure 2 shows these XP spectra obtained from the CVD as-grown ZrO_xH_y overlayers on a Cu(111) single crystal, after 973 K vacuum annealing and subsequent O₂ annealing at 673 K. The as-grown state consists of (partially) hydroxylated ZrO_xH_y, as deduced from the shift of the O 1s binding

energy as well as from the Zr 3d_{3/2} peak position at 183.2 eV and the corresponding HREEL spectra of the “precursors state” in Figure 4.

Vacuum annealing at 973 K causes minor changes (slight loss of Zr-OH indicated by a shift of the Zr 3d signal towards lower binding energies), as well as a broadening of the O 1s peaks due to the presence of a second state, namely ZrO₂, at 530.4 eV. The feature at ~535 eV in the O 1s region is a Cu LMM Auger line. The apparent intensity increase in Figure 2 (973 K annealing) arises from a lower O 1s intensity. The relative intensity of the Cu LMM Auger line related to the Cu 2p_{3/2} photoemission line is approximately (not exact due to different attenuations) constant for all three shown spectra of Figure 2. The vacuum-annealed state now is clearly a mixture of both, ZrO₂ and Zr(OH)₄, and probably also intermediate species such as ZrO_x(OH)_{4-2x}. The incomplete loss of hydroxylated Zr with annealing at 900 K of an CVD-prepared layer using ZTB on Si(111) was also found by Cameron et al [31].

Treatment in O₂ (673 K) leads to fully oxidized ZrO₂ with a Zr 3d BE consistent with literature values (182.4 eV). From the spectra shown in Figure 2 it becomes clear that annealing at 973 K is an effective way of carbon removal. Only a small peak in the C 1s region persists, which cannot be removed in oxygen. Only by performing oxidative pre-treatments before annealing at 973 K, carbon can be removed completely (cf. Figure 3).

3.A.3 Reductive treatments

The motivation to carry out reductive treatments of the CVD-prepared films is mainly fueled by previous experiments on sputter-prepared “inverse” (i.e. ZrO_x-on-Cu) catalysts, which showed a high CO₂-selectivity in methanol steam reforming, if the pre-catalyst contained a Zr metal component [15]. In order to obtain comparable CVD-based pre-catalyst states, reductive treatments have been carried out. As summarized in Table 1, different reductive post-treatments of the prepared film do neither affect the position of the Zr 3d peak nor the O quantity (spectra are not shown because of qualitative similarities). This is also true upon

applying very harsh reduction conditions as e.g. in 14 W cold hydrogen plasma. Already hydroxylated Zr remains hydroxylated and is apparently very stable, indicating that the Zr-O bond cannot be cracked. Table 1 lists the treatment conditions and the associated Zr 3d_{5/2} binding energies for various reductive treatments. A binding energy shifted to 183.0-183.1 eV is characteristic for hydroxylated Zr. Upon H⁺ sputtering, the ion gun designated for Ar⁺ sputtering for sample cleaning was operated with a hydrogen background pressure of 1x10⁻⁴ mbar (ion energy 1 keV, ion current ~3 μ A). As no shift is observed in the Zr 3d binding energy, no Zr reduction takes place.

Table 1: Summary of reduction treatments of the as grown films, with Zr coverages obtained from the XPS overlayer model (see section 2.4.) and associated Zr 3d peak positions.

Substrate	Exposure	Zr cov. / ML	Reductive Treatment	Zr 3d _{5/2} BE / eV
Cu(111)	~2000L ZTB	0.06	5x10 ⁻⁶ mbar H ₂ , 673 K, 15 min	183.1
Cu(111)	~2000L ZTB	0.04	5x10 ⁻⁶ mbar H ₂ , 873 K, 15 min	183.1
Cu(111)	~2000L ZTB	0.14	H-plasma (14 W), 10 min	183.1
Cu(111)	~2000L ZTB	0.06	H ⁺ -sputtering, 5 min	183.0

3.A.4. Oxidative treatments

Similar to the reductive treatments, also oxidative treatments of ZrO_x on Cu systems have been observed to have a direct impact on the catalytic properties. For best appreciating the depth of interpretation, Figure 3 (XPS results) and Figure 4 (HREELS data) are jointly discussed. As shown in Table 2 and Figure 3, treatments in oxygen (besides effective carbon removal) induces a corresponding Zr 3d binding energy shift to lower BE's, even lower as compared to the literature position of ZrO₂ [33]. The Cu 2p_{3/2}, O 1s and Zr 3d binding energies are jointly listed in Table 2. The Zr 3d_{3/2} peak shift is interpreted mainly in terms of the loss of hydroxyl groups. However, the HREEL spectra still indicate the presence of Zr-OH (cf. Figure 4, panel b, "O₂ treatment"). Also the intensity of the Zr-O vibrations between 493 and 700 cm⁻¹ increase with oxidative treatment, indicating a carbon clean-off reaction.

The effect results in higher intensity of the of ZrO_xH_y species and explains why the Zr-OH peak at 3673 cm^{-1} even slightly increases. With the HREEL spectra in mind, special care needs to be applied upon interpretation of the observed binding energy shifts. The downward shift of the Zr 3d peak from $\sim 183.0\text{ eV}$ to 182.0 eV could be interpreted as dehydroxylation. However, for the formation of oxidized surface species (by oxygen treatment) many other effects such as partial shape effect, delayed charge transfer from the substrate or charging, mostly likely even a combination of these effects, may contribute to the peak position. The relevance of such phenomena is also corroborated by the fact that the O 1s BE and Zr 3d BE shift are up to a certain extent parallel. This situation makes the chemical shift rather unspecified to the actual binding character of Zr and therefore hard to interpret.

According to HREELS, upon consideration of the carbon clean-off effect, the Zr-OH signal at 3673 cm^{-1} was normalized to the Zr-O vibration at 692 cm^{-1} with the result that 73 % of initial Zr-OH groups remain after O_2 treatment. This downshift in binding energy with O_2 treatment is directly correlated with an activity decrease in methanol steam reforming as discussed in detail in the catalytic section. After high-temperature annealing, the oxygen-induced low binding energy shift is restored and approaches literature values for Zr 3d and O 1s in fully oxidized ZrO_2 .

Figure 3: XP spectra collected on a Cu(111) single crystal covered with 0.6 ML ZTB. Starting from a freshly at 693 K exposed sample, marked as “as grown”, oxidation and annealing was performed (reverse order to Figure 2). Cu 2p_{3/2}, C 1s, O 1s and Zr 3d peaks are shown in separate sub-panels.

With corresponding annealing of the oxidized sample in vacuum at 973 K, a total loss of Zr-OH was found in HREEL spectra (Figure 4, panel a: “973 K annealed”), complemented by a Zr 3d binding energy shift to higher values in the XP spectra (Figure 3). This shift indicates partial reversal of the O₂- induced low BE shift. The Zr 3d peak position at 182.4 eV after the vacuum annealing is perfectly in line with listed literature value for bulk ZrO₂ [33]. STM images (shown in the SI in Figure S1) indicate hexagonal holes within an otherwise flat Cu surface, which is in correlation with the increase of the Cu 2p_{3/2} peak intensity in XPS (Figure 3). This interpretation is also substantiated by the significant loss of Zr-O vibrations around 700 cm⁻¹ due to the loss of surface Zr-species.

Oxidative annealing treatments of the as-grown CVD film using H₂O (5×10⁻⁷ mbar H₂O at 696 K) causes no shift and no intensity change in neither the Zr 3d, C 1s, O 1s nor the Cu 2p_{3/2} region (corresponding binding energies listed in Table 2, spectra shown in SI) and no

changes in the HREEL spectra. This indicates saturation of hydroxylation of Zr is reached even before treatment with water and/or that additional heterolytic water splitting on the already existing ZrO_xH_y species is kinetically hindered.

Table 2: Summary of oxidative treatments of the as-grown films in either O_2 or H_2O , with associated Cu $2p_{3/2}$, C 1s, O 1s and Zr 3d peak positions. The corresponding spectra are shown in the SI.

Treatment CVD followed by	BE Cu $2p_{3/2}$ / eV	BE C 1s / eV	BE O 1s / eV	BE Zr 3d / eV
5×10^{-7} mbar O_2 , 15 min, 673 K	932.9	-	530.0	182.0
5×10^{-7} mbar O_2 , 15 min + 973 K vacuum annealed	932.9	-	530.6	182.4
5×10^{-7} mbar H_2O , 15 min, 673 K	932.9	284.5	530.9	182.9

Figure 4: HREEL spectra of the as-grown CVD-prepared ZrO_xH_y overlayer on Cu and two selected post-treatment experiments. Primary counts and FWHM: a) 2.21×10^5 cps/33 cm^{-1} b) 1.27×10^5 cps/32 cm^{-1} c) 3.67×10^5 cps/33 cm^{-1} . Cu-O vibrations due to partial oxidation of the substrate during reaction contribute in a minor way to the Zr-O vibrations around 600 cm^{-1} . A reference spectrum for Cu-O can be found in the SI (Figure S2).

3.B. Catalytic measurements in methanol steam reforming

3.B.1. Pure Cu foil

As there are some contradicting facts about the catalytic performance of pure Cu in MSR in literature [34, 35], the properties of the polycrystalline Cu foil used herein have been characterized in detail to identify solely Cu-related catalytic effects. Furthermore, they should allow a more detailed discussion of the catalytic activation of Cu via a sub-monolayer ZrO_xH_y coverage in the used batch-reactor setup. The Cu-foil (Alpha Aesar, 99.9999 % purity) was UHV-cleaned via several cycles of sputtering/annealing until only Cu was seen in XPS. The reactivity pattern of the clean foil in MSR is shown in Figure 5, panel a). There is clear evidence that the ultra-pure Cu foil is not reactive at all in MSR in our batch reactor setup. Panel b) shows the MSR performance of the same sample after a preceding oxidative steam reforming experiment (OSR, same experimental protocol as for MSR, but 12 mbar methanol + 24 mbar water + 6 mbar O_2). Cu is obviously activated to some extent by the O_2 co-feed, but only toward formaldehyde formation [4, 5, 16]. However, both on pure Cu and O_{sub} -activated Cu, no (quantitative) water activation is seen and therefore no CO_2 is formed. In addition, full dehydrogenation on Cu is also not accessible as indicated by the inexistent CO formation. Therefore, only the first steps in MSR, the activation of methanol to create weakly surface bound methoxy ($-\text{O}-\text{CH}_3$) species, which then become selectively dehydrogenated toward formaldehyde, take place, followed by formaldehyde desorption. A similar behavior can be seen for a polycrystalline Cu foil with lower purity (99.95%, Goodfellow). This MSR experiment is shown in Panel C of Figure 5. Formaldehyde is the main product, but before complete deactivation takes place, also CO_2 as a minority component is formed. Most likely, trace impurities on the surface allow for measurable water activation and, thus, total oxidation toward CO_2 . Nevertheless, full dehydrogenation to CO is absent in the reactivity pattern.

Figure 5: MSR reactivity for different polycrystalline Cu foils: a) clean, 99.9999 % purity, b) O₂ exposed via preceding OSR, 99.9999 % purity, c) clean, lower nominal purity: 99.95 %. Reaction conditions: 12 mbar methanol, 24 mbar water, 8 mbar Argon and He added to 1 bar total pressure. After an equilibration time of 10 min, a temperature ramp of 10 K min⁻¹ up to 623 K was performed, followed by an isothermal period at 623 K.

3.B.2. CVD-prepared ZrO_xH_y on Cu foil

In Figure 6, the selectivity patterns/ activities of pure Cu (a), pure ZrO₂ (d) and two samples of ZrO_xH_y (b,c) are shown. Onset of product formation was observed between 580 and 600 K. For the lowest ZrO_xH_y coverage, the catalyst is highly formaldehyde-selective. However, with increasing coverage pathways to CO and CO₂ get accessible, but are not very effective as the rate maxima of the latter remain below the formaldehyde maximum. Figure 7 in turn shows the plot of reaction rate versus ZrO_xH_y coverage for all studied ZrO_xH_y/Cu samples. Table 3 sums up all reaction rate maxima and the corresponding turnover frequencies for the seven tested samples. The total number of “free” surface Cu sites was calculated from the substrate

area under consideration of the ratio of free Cu surface from ISS (Figure S4) and an average surface atom density of 1.65×10^{15} Cu atoms/cm² (average of (111) and (100) surface).

Table 3: Reaction rates and estimated turnover frequencies for the five ZrO_xH_y/Cu samples and the pure Cu and ZrO₂ reference catalysts.

Sample No.	Sample Descriptor	Estimated number of surface Cu sites	Maximum formation rate / 10^{-3} mbar min ⁻¹			Maximum turn over frequency based on surface Cu sites / s ⁻¹		
			CO ₂	H ₂ CO	CO	CO ₂	H ₂ CO	CO
1	Ox. Zr foil (ZrO ₂)	0	0	0	0	0	0	0
2	CVD prep. ZrO ₂ on Cu	5.54×10^{15}	0	0	0	0	0	0
3	CVD prep. ZrO ₂ on Cu	1.02×10^{16}	0.021	0.004	0.004	0.05	0.23	0.05
4	CVD prep. ZrO ₂ on Cu	9.93×10^{15}	0.020	0.010	0.008	0.16	0.23	0.09
5	CVD prep. ZrO ₂ on Cu	8.99×10^{15}	0.014	0.009	0.007	0.12	0.18	0.09
6	CVD prep. ZrO ₂ on Cu	9.03×10^{15}	0.017	0.012	0.010	0.15	0.22	0.13
7	Polycrystalline Cu foil	1.16×10^{16}	0	0	0	0	0	0

Figure 6: MSR experiments for a) clean Cu, b) Sample 5: ZrO_xH_y (0.45 ML) on Cu foil, c) Sample 3: ZrO_xH_y on Cu foil (0.21 ML) and d) clean ZrO₂. Reaction conditions: 12 mbar methanol, 24 mbar water, 8 mbar Argon and He added to 1 bar total pressure. After an

equilibration time of 10 min, a temperature ramp of 10 K min^{-1} up to 623 K was set, followed by an isothermal period at 623 K.

Figure 7: Plot of reaction rate versus ZrO_xH_y coverage as estimated from XPS. The CO/CO_2 rate maximum does not coincide with the formaldehyde maximum, as a consequence of different reaction sites for partial dehydrogenation, H_2 desorption and total oxidation.

By varying the thickness of the ZrO_xH_y overlayer on the Cu substrate (i.e. the extent and chemical nature of the $\text{ZrO}_x\text{H}_y/\text{Cu}$ interface) beneficial and disadvantageous selectivity steering bi-functional synergisms can directly be determined and correlated with the spectroscopic and structural results (shown above) to establish direct structure-activity and -selectivity relationships. The related spectroscopic data for the 7 samples (six of them shown in Figure 7) can be found in XPS section 3.C.

The reactivity pattern of CVD prepared ZrO_xH_y on Cu differs from what to expect from the deliberate hydroxylation and the abilities of sputter-deposited ZrO_xH_y on Cu [15]. At first, it appears surprising that no MSR-effective H_2O activation could be observed, but a selectivity shift towards formaldehyde especially for low ZrO_xH_y coverages was confirmed (see Figure 7). This finding is interesting from two points of view: firstly, Cu is activated by the ZrO_xH_y

CVD preparation similar to the pre-activation with co-fed O_2 , but more efficiently. The ability of pure Cu to activate methanol is increased with O_{sub} in the Cu lattice [4]. Alternatively, the oxidized/hydroxylated Zr species could also take the role of altering the Cu lattice [36].

The observed activation could in principle also be associated with an effect of electronic modification (and thus, catalytic activation of the thin oxide layer by the Cu substrate) as the mean overlayer thickness estimated from combined XPS/ISS results and from DFT calculations is preferentially around 2 ML (cf. Figure S3). However, the formaldehyde formation rate decreases with higher ZrO_xH_y coverage, despite this constant layer thickness, which contradicts a purely oxide-surface related promotion.

In fact, the formaldehyde rate maximum does not coincide with the rate maxima of CO and CO_2 . Expectedly, a reaction mechanism occurring directly at a geometrically optimized number of Cu/ ZrO_xH_y interfacial sites should give rise to a rate maximum around coverage of 0.5 (see Figure 7). However, it rather appears that the formaldehyde formation rate is correlated with a relatively large fraction of chemically unaltered and/or free Cu metal surface sites, as it reaches its maximum at rather low ZrO_xH_y coverages around 0.2 ML. We, thus, rather suggest a mechanism involving “structure-insensitive” selective dehydrogenation of methanol to formaldehyde (desorbing directly to the gas phase) on extended clean Cu surface patches, followed by relatively fast diffusion of the simultaneously formed H atoms over mesoscopic distances to nearby phase boundary sites, which eventually help to lower the intrinsically high H_2 desorption barrier on the clean Cu surface. In this “H-surface diffusion” scenario, the optimum phase boundary dimensions are most likely below the 0.5 ML “geometric” optimum.

On the CVD-prepared system, up to 623 K only inefficient onward reaction with activated water takes place, represented by the overall low CO_2 formation rate shown in Figures 6 and 7. A relative maximum of CO_2 production was observed on the 0.45 ML ZrO_xH_y covered

surface, suggesting a slightly improved total oxidation reaction channel at the “geometric” phase boundary optimum.

3.B.3. CVD prepared ZrO_xH_y in MSR up to 873 K and the role of hydroxylation

In situ XP spectra were recorded under MSR conditions (total pressure 0.3 mbar, methanol:water=1:2) and the respective results are shown in Figure 8. After the CVD growth at 693 K, the sample was cooled to room temperature and exposed to the MSR gas phase (first spectrum). The initial CVD-induced hydroxyl species are largely decomposed around 550 K and hydroxylation is hardly re-established until 623 K, resulting in a Zr 3d peak shift down to a BE of 182.4 eV (literature value for bulk ZrO_2 [33]). Relevant temperatures for a good MSR catalyst are rather below 623 K. Thus, this maximum temperature was chosen for the previous catalytic experiments of Figure 6, which, as a consequence of dehydroxylation, show only little CO_2 -formation in this temperature range. Moreover, the data of Figure 8 confirm the previously only “*ex situ* - XPS” observed dehydroxylation of ZrO_xH_y after the MSR experiments at 623 K (cf. Figure 6). With further increasing temperature, again an increasing degree of hydroxylation is observed, as indicated by the Zr 3d peak shift to higher binding energies. This “high-temperature” hydroxylation most likely arises from now kinetically accessible water activation pathways. In order to understand the catalytic consequences of this effect, a corresponding temperature-programmed MSR experiment was performed up to a maximum temperature of 873 K (Figure 9).

Figure 8: *In situ* XPS spectra of a ZrO_xH_y overlayer (~ 0.5 ML) on the polycrystalline Cu foil. Initial hydroxylation after the CVD process is depleted until ~ 550 K, but hydroxyl groups are then re-established at higher temperatures. This “high-temperature” water activation opens the total oxidation pathway as shown in Figure 9. MSR conditions: 0.1 mbar methanol, 0.2 mbar H_2O .

A significantly higher CO_2 formation rate than on clean Cu could be detected in the temperature range up to 873 K in MSR for ~ 0.5 ML ZrO_xH_y deposited on polycrystalline Cu. CO_2 can now be formed via the reaction of activated methanol and activated water above ~ 700 K, in agreement with the re-hydroxylation beyond ~ 623 K shown in Figure 8. CO formed above ~ 700 K via the inverse water gas shift reaction decreases the CO_2 -selectivity of the catalyst at higher reaction temperatures.

Figure 9: MSR experiment up to 873 K on polycrystalline Cu modified by ~0.5 ML ZrO_xH_y . CO_2 is formed above ~623K, as water activation-dependent reaction pathways become accessible (cf. XPS data in Figure 8).

Phenomenologically, the loss of $-\text{OH}$ groups while heating up to 623 K (*in situ* data of Figure 8) and, as a lookahead, the (*ex situ* verified) absence of the latter after MSR at 623 K (cf. Figure 11 and Table 5 in section 3.C.), suggest a too weak bonding of at least the originally present CVD-preparation-induced $-\text{OH}$ groups under stationary reaction conditions. This is clear especially in comparison to the sputter-prepared “intermetallic pre-catalyst” state. The latter shows a considerably higher CO_2 selectivity in combination with “active” hydroxylation at 623 K under otherwise identical conditions [14].

From a very general viewpoint, for MSR the reaction of intermediate formaldehyde with sufficiently stable (but not too stable) $-\text{OH}$ groups to CO_2 represents the most crucial reaction step, being intimately linked to efficient and reversible water activation [37]. In analogy to the “bifunctional” mechanism postulated for the Cu/ZnO_x system [13], we suggest that methanol is activated and formaldehyde formed on Cu sites and the reactive $-\text{OH}$ species need to be formed continuously at the $\text{Cu}/\text{ZrO}_x\text{H}_y$ interface.

In case of the initially intermetallic Cu/Zr⁰ pre-catalyst, metallic Zr⁰ is (as a consequence of the sputter process) rather statistically distributed in/on Cu, likely leading to highly dispersed and hydroxylated ZrO_xH_y species upon reaction with water at 623 K under MSR conditions [15]. Obviously, the highly specific intermetallic precursor state somehow allows reversible water splitting/ Zr hydroxylation already at temperatures around 600 K. In contrast, on the CVD-prepared phase boundary the analogous bifunctional situation is only established at much higher temperatures around 700 K, as will be demonstrated in the following chapter 3.B.3.

At present it would remain pure speculation why the barriers for heterolytic water splitting and the stabilities of the resulting –OH groups are considerably different for the CVD- and sputter-prepared model catalysts. In the absence of detailed structural information regarding the dimensions, the chemical and the structural (polymorphic) nature of the two phase boundary models, we limit ourselves to the presentation of the phenomenological results.

3.B.4. Methanol steam reforming after oxidative treatments

If the CVD-prepared films are exposed to O₂ at 673 K prior to MSR (with 623 K maximum temperature), all formation rates are without exception lowered. The MSR selectivity pattern and activity shown in panel b) in Figure 10 was obtained after heating for 5 min at 673 K in 5x10⁻⁷ mbar O₂. The reaction rates are significantly reduced, as compared to the “as-grown” sample in panel a). Further heating for 10 min under the same oxidative conditions at the same temperature leads to an almost complete loss of activity, as shown in panel c).

As revealed in the post-treatment study (section 3.A.4), initially present Zr-OH species are depleted by the oxygen treatments, although, as shown by HREELS, not instantly and completely. The general loss of activity can therefore be correlated with the loss of Zr-OH groups. This implies that a certain degree of hydroxylation is also important for partial

oxidation of methanol to formaldehyde and that the promotion of H_2 desorption by the ZrO_xH_y islands (as suggested in section 3.B.2) is somehow also linked to the presence of $-OH$ species.

This result allows to speculate about the role of Zr-OH groups in the MSR mechanism. It is plausible that there are two different kinds of Zr-OH groups, those at the interface with Cu and those on ZrO_xH_y islands, not being accessible from interfacial sites. These non-interfacial Zr-OH species can be reached by $-H$ atoms via hydrogen spillover on the oxide resulting in H_2 clean-off and consequently, partial oxidation activity. Interfacial Zr-OH groups, however, might not only catalyze H_2 formation, but also trigger full oxidation either by reaction with Cu-activated methanol itself or, probably more likely, by providing $-OH$ groups by water activation at the surface that can then react with activated methanol species.

Figure 10: Methanol steam reforming reaction on a ZrO_xH_y/Cu sample, prepared using 2000 L ZTB at 693 K, panel a) (corresponding to a coverage 0.21 ML). The sample was

subsequently treated in O₂ for 5 min at 5×10^{-7} mbar O₂ (b) and for 10 min at 5×10^{-7} mbar O₂ (c), both at 673 K. Reaction conditions: 12 mbar Methanol, 24 mbar water, 8 mbar Argon and He added to 1 bar total pressure. After an equilibration period of 10 min, a temperature ramp of 10 K min⁻¹ up to 623 K was set, followed by an isothermal period at 623 K.

3.C. XP spectroscopy before and after methanol steam reforming

With the discussed (de)hydroxylation behavior of the films obtained by several treatments in mind, the state of the film after a catalytic MSR reaction is particularly worthwhile to discuss. For the most direct comparison to the catalytic experiments, characterization was carried out on the polycrystalline Cu foil instead of on a Cu (111) single crystal. The obtained film after CVD (2000 L at 693 K) in the as-prepared state is very similar to that of the single crystal: A Zr 3d_{3/2} peak shifted up to 0.8 eV higher binding energies with respect to the literature ZrO₂ position and O 1s binding energy that is significantly higher than for oxygen in ZrO₂ results. A shoulder towards lower binding energy is noticeable for the Zr 3d as well as for the O 1s peak, indicating the presence of a rather small fraction of ZrO₂ already in the “as-grown” state (Figure 11).

It is worth noting that a metallic Cu peak at a highly constant BE of 932.9 eV is always found in any experiment. However, Cu in neither of the above-discussed treatments (nor after the catalytic reaction) shows a trend to form oxides, being clearly indicated by the strict absence of a satellite peak around 944.0 eV.

After catalysis, all peaks except Cu 2p shift. For the Zr 3d_{3/2} it is safe to state that a loss of hydroxyl groups takes place. This is determined from the Zr 3d peak position that approaches the literature position for ZrO₂ [33] and the comparison with the data on the single crystal and correlating HREEL spectra (section 3.A.). A minor distribution of an even further down shifted state even slightly below (Zr 3d peak after reaction 182.3-182.0 eV) the ZrO₂ bulk position is found. This shift is very similar to what was found (in a more pronounced way)

after oxygen treatment of a ZrO_xH_y overlayer, causing the above-described deactivation. Obviously, an oxidative deactivation also during MSR takes place. The O 1s binding energy approaches 530.4 eV, the literature BE for ZrO_2 , with a slight shoulder towards lower BE. Note that neither under reductive conditions nor under H_2O treatments such a Zr 3d_{3/2} binding energy shift was found. Obviously, the specific MSR mechanism destabilizes the OH groups, (e.g. via reactive consumption toward the hydroxymethoxy intermediate [37]), but they can be preserved under H_2O or H_2 treatments (and under any other reductive conditions). A new component in the C 1s spectra with a BE of around 284.3 eV appears after the MSR experiment and is interpreted as near-surface sp^3 carbon.

Figure 11: Representative XP spectra collected on the CVD-prepared $\text{ZrO}_x\text{H}_y/\text{Cu}$ foil before and after the MSR experiment. The peak shifts indicate dehydroxylation of the overlayer being comparable to the post-oxidative treatments described above.

As outlined earlier, for the catalytic experiments, seven samples with varying ZTB dosing (in Langmuir), resulting in various ZrO_xH_y coverages, have been prepared. Sample 1 is an

overlayer that was so thick, that no Cu could be seen either with XPS or ISS (>5000 L), whereas Sample 7 represents clean Cu. For sample 2-6, the exposure was varied between 50 and 5000 L. As described in the experimental section (2.4.), two different XPS overlayer models were applied to all films to estimate the substrate coverage/overlayer thickness. The results are listed in Tables 4 and 5.

The C 1s binding energy in Table 4 shows a tendency towards lower binding energy after MSR. This is due to the different chemical nature of carbon stemming from the ZTB precursor and the C 1s species arising from the decomposition of methanol. However, all carbon found is sp^3 -type. The O 1s region shows a superposition of many states (also including carbon oxygenates), a peak deconvolution therefore was not performed. For the Zr coverage estimation, it is necessary to state the limitation of the coverage calculation caused by the neglect of the electron attenuation. Especially when a high carbon coverage after MSR appears, the model pretends an increasing Zr coverage with MSR. However, this is an artefact due the shielding of the Cu $2p_{3/2}$ signal and a consequently higher Zr/Cu ratio obtained by the calculations. With this limitation in mind, the coverage model nevertheless gives a quantitative insight and can be furthermore correlated with catalytic results. For the Zr $3d_{3/2}$ peak position a similar shift as discussed above was observed for all samples, with the measured binding energies also listed in Table 4.

Further, in Table 5 the XPS results are combined with ion scattering quantification (selected data in Figure S4). Note that the XPS atomic percent data are only listed for informative reasons but do not represent a reliable basis for interpretation due to the approximation of a homogeneous sample. This is clearly not the case in our substrate-overlayer model. The XPS thickness calculation (considering electron attenuation through the overlayer) with a film thickness (in nm) as result are very close to the coverage estimation (no electron attenuation considered) because of the low coverage and the consequently low impact of photoelectron shielding by the overlayer. A mean particle height was estimated from XPS coverage and ISS

and is close to 2 ML on average for all samples. The propensity to form 1-2 ML ultrathin layers was also highlighted in the DFT calculations (Figure S3).

Table 4: XPS analysis of the Cu foil covered with different amounts of ZrO_xH_y (as outlined in Table 5) before and after the catalytic methanol steam reforming reaction.

Sample	C 1s		O 1s	Zr 3d	
	Coverage / ML	Peak Position / eV	Peak Position / eV	Coverage /ML	Zr 3d _{5/2} Peak Position /eV
2, before MSR	0.79	284.6	531.0	1.00	182.8
2, after MSR	3.10	284.5	531.7	(1.60)	182.3
3, before MSR	0.14	284.8	531.4	0.21	182.6
3, after MSR	0.91	284.7	531.2	0.27	182.0
4, before MSR	0.60	284.6	531.8	0.27	182.6
4, after MSR	1.80	284.6	531.9	0.21	182.0
5, before MSR	0.43	284.9	531.1	0.45	183.0
5, after MSR	1.71	284.4	532.0	0.52	182.3
6, before MSR	1.53	284.8	531.2	0.38	182.7
6, after MSR	3.50	284.6	531.6	(0.83)	182.1

Table 5: XPS and ISS data and interpretation of the seven catalytic samples, i.e. of the Cu foil covered with different amounts of ZrO_xH_y .

Sample No.	XPS / atomic% Zr	ISS / %Zr	XPS coverage / ML	XPS thickness / nm	mean particle height / ML
1	100	100	inf.	inf.	n.a.
2	10.1	52.00	1.00	0.51	2.00
3	3.00	11.49	0.21	0.11	1.90
4	3.10	14.10	0.27	0.14	1.90
5	5.50	22.20	0.45	0.24	2.00
6	3.30	21.80	0.38	0.20	1.70
7	0.00	0.00	0.00	0.00	0.00

4. Conclusions

In conclusion, chemical vapor deposition of ZTB on Cu samples leads to a partially hydroxylated and fully oxidized $\text{Zr}^{+4}\text{O}_x\text{H}_y$ species, which exhibits a pronounced catalytic synergism between the ZrO_xH_y overlayer in the sub-monolayer regime and Cu. The catalytic

performance differs from that of sputter-grown ZrO_xH_y layers on Cu, which exhibit a partially oxidized Zr^0 metal precursor state. In due course, these CVD-grown Zr-OH groups are much less active for water redox chemistry in MSR because reversible hydroxylation under reaction conditions does not take place. Therefore, water activation-dependent pathways are not accessible. However, Cu indeed gets activated and this in turn causes increased formaldehyde formation rates, as it is needed for the industrially highly relevant partial oxidation of methanol to formaldehyde. As the most crucial outcome, and further strengthening the assumption that only a dedicated Cu- ZrO_xH_y interface with *in situ* formed hydroxylated sites in combination with oxygen-poor metallic Cu/Zr starting compounds leads to enhanced CO_2 selectivity, this appears to be the only way to form the ZrO_xH_y surface structure that is responsible for the necessary H_2O activation. Although the presented results do obviously not offer a direct pathway to a Cu/ ZrO_x catalyst with enhanced CO_2 selectivity, they clearly lay out the basis for a knowledge-based pathway of catalyst design with enhanced CO_2 selectivity, which needs to meet the following criteria: a Cu/Zr metallic precursor with Cu in excess (~ 50-70 at% Cu) to avoid ZrO_2 clustering, oxygen-free preparation to avoid large amounts of oxygen in Cu and a corresponding post-treatment under MSR conditions for reversible *in situ* hydroxylation and formation of the ZrO_xH_y -Cu interface.

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Graphical Abstract